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K₂S₂O_{8/}MoO₃: An oxidation reagent for benzylic alcohols and trimethylsilyl and tetrahydropyranyl ethers

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The oxidation of benzylic alcohols and trimethylsilyl (TMS) and tetrahydropyranyl (THP) ethers to their corresponding carbonyl compounds with $K_2S_2O_8$ is efficiently promoted by the presence of MoO_3 .

Keywords: oxidation, alcohols, trimethylsilyl ethers, tetrahydropyranyl ethers, K₂S₂O₈

Aldehydes and ketones are important in organic synthesis.¹ The controlled oxidation of alcohols to the corresponding carbonyl compounds is widely used.² Several reagents for the oxidation of alcohols have been reported including chromium(VI)-based oxidants,²⁻⁴ manganese(VII)-based oxidants,^{2,5} ruthenium-based oxidants^{2,6} and hypervalent iodine.² Most of these methods suffer from disadvantages such as long reaction times, low yields, undesirable side reactions, expensive or toxic reagents, tedious work-up procedures and

the need for an excess of the reagent. Thus there is still a need to introduce new reagents for this conversion.

Recently our research program has been focused on the development of new methods for the oxidation of organic compounds.⁷⁻¹¹ In continuation of these studies we have found that the oxidation of benzylic alcohols to their corresponding carbonyl compounds with $K_2S_2O_8$ is efficiently catalysed by MoO₃ (Table 1, Scheme 1).

Entry	Substrate	Product	Time/h	Yield/%	M.p. or b.p. (°C) /kPa	
					Found	Reported ¹³
1	СН2ОН	СНО	0.68	90	180–181/101	179/101
2	СН2ОН	СНО	1.4	90	209/101	208/101
3	сі — Сн ₂ он	сіСно	0.6	92	44–46	46
4	CH ₂ OH	СНО	1	85	226–228/101	228–230/101
5	Br CH ₂ O	Br CHO	0.34	87	57–59	55–58
6	СН2ОН	СНО	1.36	80	196–198/101	198–200/101
7	Me Me ₂ HC CH ₂ OH	Me Me ₂ HC CHO	0.34	80	79–82/101	82-84/101
8	СН2ОН	СНО	0.85	80	100–102/101	102/101
9	PhH ₂ CO CH ₂ OH	PhH ₂ CO CHO	1.1	75	68–70	70–72
10	CH ₂ OH	СНО	3	50	57–59	58
11		0 ₂ N 0 ₂ N-Сно	7	50	103–105	106
12	С		0.5	90	199–201/101	202/101
13			4.6	92	50–52	47–49
14	OH		1.8	90	39–42	37–40

^aProducts were characterised by comparison of their physical and spectral data with authentic samples. ^bYields refer to isolated yields.

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Different benzylic alcohols were subjected to this oxidation in refluxing CH₃CN–H₂O. Over-oxidation of the products was not observed under the selected conditions. Although in most cases the yields of the products were relatively high, in the case of the benzylic alcohols containing nitro group (Table 1, entries 10 and 11) the rate of the reaction was so slow that after a long reaction time only a small amount of the substrate was converted to the desired product. After the oxidation of benzylic alcohols, we were interested in extending the applicability of the reported reagent system to the oxidation of benzylic trimethylsilyl and tetrahydropyranyl ethers (Scheme 2).

As shown in Table 2, the oxidative deprotection of TMS and THP ethers occurs efficiently using $K_2S_2O_8$ in the presence of MoO₃. All the reactions were performed in refluxing CH₃CN–H₂O in good to high yields.

Table 2 Oxidative deprotection of TMS and THP ethers^a

Entry	Substrate	Product	Time/h	Yield/%	M.p. or b.p. (°C)/kPa	
					Found	Reported ¹³
1	CI-CH2OTMS	сі—Сно	2	92	44–46	46
2	CH ₂ OH	СНО	1.5	90	209/101	208/101
3		СНО	2	85	226–228/101	228–230/101
4	CH ₂ OTMS	СНО	0.3	92	196–198/101	198–200/101
5	MeO CH ₂ OTMS	МеО СНО	0.3	90	100–102/101	102/101
6	CTMS OTMS		0.43	90	199–201/101	202/101
7	OTMS	r li	0.4	85	39–42	37–40
8			0.7	87	50–52	47–49
9			1.1	80	91–93	95
10	CI-CH2OTHP	сіСно	0.34	85 ^c	44–46	46
11		СНО	0.34	82°	209/101	208/101
12		СНО	1.5	92°	226–228/101	228–230/101
13	CH ₂ OTHP	CHO Me	0.34	90°	196–198/101	198–200/101
14	MeO CH ₂ OTHP	Мео сно	0.34	90°	100–102/101	102/101
15	ОН		0.85	85°	50–52	47–49
16	OTHP	Č,	0.34	87°	39–42	37–40
17	O ₂ N CH ₂ OTHP	O2N CHO	6	70 ^c	103–105	106

^aProducts were characterised by comparison of their physical and spectral data with authentic samples. ^bYields refer to isolated yields.

^c1 mmol of K₂S₂O₈ was used.



Table 3 Comparison of some of the results obtained by our method (1), with some of those reported by using KMnO₄/ZrOCl₂.8H₂O (2) 5 and quinaldinium dichromate (3) 12

Entry	Substrate	Yield/% (h)			
		(1)	(2)	(3)	
1	PhCH ₂ OH	90 (0.68)	95 (3.5)	70 (3)	
2	сі————————————————————————————————————	92 (0.6)	94 (3.5)	69 (4)	
3	PhCH(OH)Ph	92 (4.6)	94 (4.5)	72 (3)	

Note that the reactions in the absence of MoO₃ or in dry CH₃CN were so slow that a considerable amount of the starting material was recovered unchanged even after extended period of time. To show the efficiency of the selected method, Table 3 compares some of the results with some of those reported in the literature.5,12

In conclusion, we have demonstrated an efficient method for the oxidation of benzylic alcohols and trimethylsilyl and tetrahydropyranyl ethers using K2S2O8 in the presence of MoO₃.

Experimental

Chemicals were purchased from Fluka, Merck and Aldrich. Silica gel 60 (0.063-0.2 mm, 70-230 mesh) was purchased from Merck. Products were separated and purified by different chromatography techniques, and were identified by the comparison of their m.p., IR, NMR and refractive index with those reported for the authentic samples. All yields refer to the isolated products. The purity of the substrates and the course of reaction was monitored by TLC on silica gel polygram SILG/UV 254 plates. Column chromatography was carried out on Merck kieselgel 60H.

General procedure

 $K_2S_2O_8$ (0.75–1 mmol, 0.261–0.348 g) and MoO₃ (0.2 mmol, 0.029 g) were added to a solution of the substrate (1 mmol) in CH₃CN-H₂O (2:1, v/v) (3 ml). The mixture was refluxed for the appropriate time (Tables 1 and 2). The progress of the reaction was monitored by TLC. After completion of the reaction, the mixture was filtered and the residue was washed with CH₃CN (5 ml). The combined filtrates were concentrated on a rotary evaporator to remove most of the CH₃CN.

The residue was partitioned between saturated aqueous solution of NaCl and diethyl ether. The organic layer was washed with saturated solution of NaHCO3 and dried over MgSO4. Evaporation of the solvent followed by column chromatography on silica gel gave the corresponding carbonyl compounds in good to high yields.

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